



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/075,172	02/13/2002	Brian E. Cron	MI22-1804	7318

21567 7590 01/25/2005
WELLS ST. JOHN P.S.
601 W. FIRST AVENUE, SUITE 1300
SPOKANE, WA 99201

EXAMINER

OJINI, EZIAMARA ANTHONY

ART UNIT	PAPER NUMBER
----------	--------------

3723

DATE MAILED: 01/25/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

10/075,172

Applicant(s)

CRON, BRIAN E.

Examiner

Anthony Ojini

Art Unit

3723

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 06 July 2004.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-11 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-11 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 13 February 2002 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
 - ☐ Certified copies of the priority documents have been received in Application No. _____.
 - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Applicant's election of Group 1 (claims 1-11) and cancellation of claims 12-35 in Paper No. 3 is acknowledged.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 1,2,4 are rejected under 35 U.S.C. 103(a) as being unpatentable over **Applicant Admitted Prior Art (AAPA)** in view of **Inoue et al.** (6,443,816 B2).

With respect to claims 1,4, AAPA discloses a method for conditioning a surface of a polishing pad after chemical-mechanical polishing of a semiconductor substrate with the pad surface (18), comprising the following steps: providing a conditioning disk (24); positioning the pad with the pad surface against the conditioning stone and displacing the pad relative to the conditioning stone to rub the pad surface with the condition stone.

AAPA fails to disclose the step of exposing the pad surface to steam

Inoue et al. disclose a steam outlet nozzles (7-1 to 7-4) being configured to jet steam onto the pad surface during the conditioning of the pad (see col. 3, lines 25-51 & fig. 1).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to perform the method of **AAPA** with steam jet nozzles being

Art Unit: 3723

configured to jet steam onto the pad surface during the conditioning of the pad surface in view of **Inoue et al.** so as to dislodge and remove particulates embedded in the pad.

With respect to claim 2, AAPA fails to disclose wherein a jet steam is jetted onto the pad surface to impacts the surface with a pressure of from about **10 psig** (24psi) to **20 psig** (34psi).

Inoue et al. disclose a steam outlet port (7-1 to 7-4), the steam outlet port being configured to jet steam onto the pad surface such that the steam impacts the surface with a pressure of from about 0.01 Mpa (1.45 psi) to 0.7 Mpa (101 psi).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to provide apparatus of **AAPA** with steam jet nozzles being configured to jet steam onto the pad surface such that the steam impacts the surface with a pressure of from about 0.01 Mpa (1.45 psi) to 0.7 Mpa (101 psi) in view of **Inoue et al.** so as to dislodge and remove particulates embedded in the pad.

Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over **Applicant Admitted Prior Art (AAPA)** in view of **Inoue et al.** as applied to claim 1 above, and further in view of **Nishimura et al.** (6,332,835 B1).

With respect to claim 3, AAPA fails to disclose wherein a steam has a temperature of at least 200⁰ F as it flows through the outlet port.

Nishimura et al. disclose a steam that has a temperature of at least 200⁰ F as it flows through the outlet port (see col. 9, lines 65-67).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to perform method of **AAPA with** a steam that has a temperature

Art Unit: 3723

of at least 200⁰ F as it flows through the outlet port in view of **Nishimura et al.** so as to dislodge and remove particles from the entire surface of the pad.

Claims 5-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over **Applicant Admitted Prior Art (AAPA)** in view of **Inoue et al.** as applied to claim 1 above, and further in view of **Lorimer** (6,589,878 B1).

With respect to claim 5, AAPA, fails to disclose wherein the pad has a contaminant associated therewith prior to the conditioning, and wherein a chemical agent suitable for reacting with the contaminant is within the steam during the exposure of the pad surface to the steam.

Lorimer discloses a mixture of steam and ammonia (see col. 5, lines 4-7).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have a polishing pad with contaminant associated therewith prior to the conditioning because it is old and well known that a used polishing pad has a contaminant associated therewith prior to the conditioning.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to perform method of **AAPA** with steam comprising a chemical agent, wherein the chemical agent within the steam, reacts with the contaminant during the exposure of the pad surface to the steam in view of **Lorimer** so as to make sure particulates embedded in the pad are remove completely.

With respect to claims 6,7, AAPA fails to disclose ammonium and ammonium citrate within a steam (see col. 5, lines 4-7).

Art Unit: 3723

Lorimer discloses a mixture of steam and ammonia but fail to teach ammonium and ammonium citrate within a steam.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to provide apparatus of **AAPA with** a mixture of steam with ammonia in view of Lorimer so as to remove particle contaminates.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to provide apparatus of **AAPA with** ammonium and ammonium citrate within a steam **so as to dislodge and remove particles from the entire surface of the pad**, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. *In re Leshin*, 125 USPQ 416. See also *Ballas Liquidating Co. v. Allied industries of Kansas, Inc.* (DC Kans) 205 USPQ 331.

With respect to claim 8, AAPA is discussed in claim 6. AAPA also discloses wherein the chemical-mechanical polishing utilizes the pad to polish a copper-containing material (see page 2, [0003]).

Claims 9-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over **Applicant Admitted Prior Art (AAPA)** in view of **Inoue et al.** as applied to claim 1 above, and further in view of Brunelli (6,533,647 B1).

With respect to claims 9-11, AAPA fails to disclose wherein the pad is rubbed against a conditioning stone **during, prior, and after** the exposure to the steam respectively.

Art Unit: 3723

Brunelli discloses a method of planarizing surface of a polishing pad (240) wherein the pad is rubbed against a conditioning disk (250) during, prior, and after an exposure to a steam respectively (see fig. 4).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to perform the method of **AAPA** with conditioning disk wherein the pad is rubbed against the conditioning disk during, prior, and after an exposure to a steam respectively in view of Brunelli so as to dislodge and remove particles from the surface of the pad.

Response to Amendment

Applicant's arguments with respect to claims 1-11 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anthony Ojini whose telephone number is 703 305 3768. The examiner can normally be reached on 7 to 4 Tuesday-Friday with every other Monday off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph Hail can be reached on 703 308 2687. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Art Unit: 3723

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

A handwritten signature in black ink, appearing to read "H. J. Kim", is located in the lower right quadrant of the page.

AO
11/9/04